L Number	Hits	Search Text	DB	Time stamp
1	39743	silicon same (cleav\$3 or separat\$3)	USPAT; US-PGPUB	2002/07/04 11:23
2	1327	thinn\$3 same silicon adj oxide	USPAT; US-PGPUB	2002/07/04 11:24
3	96	(silicon same (cleav\$3 or separat\$3)) same (thinn\$3 same silicon adj oxide)	USPAT; US-PGPUB	2002/07/04 11:24
4	94	((silicon same (cleav\$3 or separat\$3)) same (thinn\$3 same silicon adj oxide)) and thickn\$3	USPAT; US-PGPUB	2002/07/04 11:25
6	0	((((silicon same (cleav\$3 or separat\$3)) same (thinn\$3 same silicon adj oxide)) and thickn\$3) and (etch\$3 or polish\$3)) and 216/24.ccls.	USPAT; US-PGPUB	2002/07/04 11:26
7	1	((((silicon same (cleav\$3 or separat\$3)) same (thinn\$3 same silicon adj oxide)) and thickn\$3) and (etch\$3 or polish\$3)) and (bragg near mirror or reflector)	USPAT; US-PGPUB	2002/07/04 11:27
5	82		USPAT; US-PGPUB	2002/07/04 11:28
8	38		USPAT; US-PGPUB	2002/07/04 11:54
9	311	silicon same (implant\$4 near5 hydrogen)	USPAT; US-PGPUB	2002/07/04 11:57
10	180	(silicon same (implant\$4 near5 hydrogen)) and (silicon same (cleav\$3 or separat\$3))	USPAT; US-PGPUB	2002/07/04 11:58
11	36	((silicon same (implant\$4 near5 hydrogen)) and (silicon same (cleav\$3 or separat\$3))) and @pd<19990210	USPAT; US-PGPUB	2002/07/04 11:59